Appl. No. 10/736,275 Atty. Docket No. 8284D Amdt. dated November 9, 2004 Reply to Office Action of August 25, 2004 Customer No. 27752

## CLAIM LISTING

This listing of claims will replace all prior versions, and listings, of claims in the application:

- 1. (Original) A process for making a mask for use in a process for curing a photosensitive material, the process comprising steps of:
  - providing a thin transparent material of substantially uniform thickness;
  - forming a pattern of opaque regions in the material according to a predetermined first pattern; and
  - embossing the material according to a predetermined second pattern.
- 2. (Original) The process according to Claim 1, wherein the first pattern substantially correlates with the second pattern to form a combined non-random repeating pattern.
- (Original) The process according to Claim 1, wherein the steps of forming the opaque regions and embossing the material are performed simultaneously.
- 4. (Original) The process according to Claim 1, wherein the step of forming a pattern of opaque regions comprises applying ink to selected regions of the transparent material.
- 5. (Original) The process according to Claim 4, wherein the selected regions comprise distal surfaces of the embossed areas of the material.
- 6. (Original) The process according to Claim 1, wherein the step of providing a thin transparent material comprises providing a transparent film.

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- 7. (Original) The process according to Claim 1, wherein the step of forming a pattern of opaque regions comprises forming opaque regions having differential opacities.
- 8. (Original) The process according to Claim 1, wherein the step of forming a pattern of opaque regions comprises forming opaque regions having gradient opacity gradually changing in at least one direction.

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